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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Kenji HAYASHI

Group Art Unit: 2879

Application No.: 10/644,573

Examiner: K. QUARTERMAN

Filed: August 20, 2003

Docket No.: 116887

For: ELECTROLUMINESCENT DEVICE, METHOD FOR MANUFACTURING THE
SAME, AND ELECTRONIC APPARATUS

REQUEST FOR RECONSIDERATION UNDER 37 C.F.R. §1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In reply to the July 27, 2006 Office Action, and the October 18, 2006 personal interview with Examiner Quarterman, reconsideration of this application is respectfully requested.

Claims 1-21 are pending in this application. Claims 13-21 have been previously withdrawn as being elected to a non-elected group of claims.

Applicant appreciates the courtesies shown to Applicant's representatives by Examiner Quarterman in the October 18, 2006 personal interview. Applicant's separate record of the substance of the interview is incorporated into the following remarks.

The Office Action, in paragraph 4, rejects claims 1-12 under 35 U.S.C. §102(e) as being anticipated by U.S. Patent No. 6,924,594 to Ogura et al. (hereinafter "Ogura"). The Applicant traverses this rejection.

The Office Action asserts that Ogura teaches many of the features as recited in the subject matter of the pending claims. Specifically, the Office Action asserts that Ogura teaches that at least the surface of the second electrode facing the barrier layer including an inorganic oxide, as positively recited in pending claim 1. This assertion is incorrect. As discussed during the personal interview, Ogura teaches an order of lamination that includes a light-emitting layer (207), a cathode (208), a barrier layer (210) and an absorption layer (211). However, Ogura does not teach that the surface of the cathode (second electrode), facing the barrier layer (210), includes an inorganic oxide. Instead, Ogura teaches the barrier layer is either silicon oxide, silicon nitride or copper phthalocyanine. Ogura is silent regarding the application of an inorganic oxide, as recited in the pending claims.

Therefore, the Office Action fails to assert a *prima facie* case of anticipation, with the applied prior art reference of Ogura, for at least the failure to show the surface of the second electrode, facing the barrier layer, including an inorganic oxide.

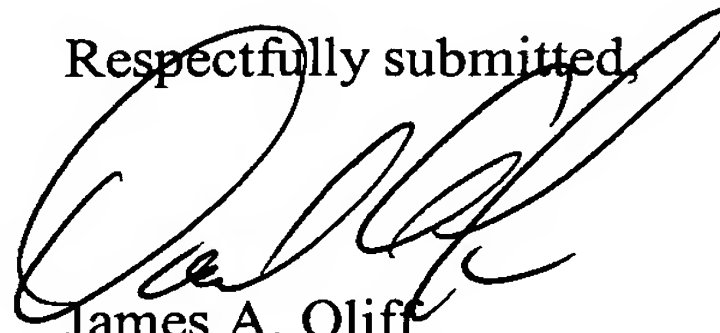
For at least the above reasons, the applied prior art reference of Ogura cannot reasonably be considered to teach, or to have suggested, the combinations of all of the features recited in at least independent claim 1. Further, claims 2-12 would also not have been suggested by the applied prior art references for at least the respective dependence of these claims on allowable independent claim 1, as well as for the separately patentable subject matter that each of these claims recites.

Accordingly, reconsideration and withdrawal of the rejection of claims 1-12 under 35 U.S.C. §102(e) as being anticipated by Ogura are respectfully requested.

In view of the foregoing, it is respectfully submitted that this application is in condition for allowance. Favorable reconsideration and prompt allowance of all pending claims are earnestly solicited.

Should the Examiner believe that anything further would be desirable in order to place this application in even better condition for allowance, the Examiner is invited to contact the undersigned at the telephone number set forth below.

Respectfully submitted,



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Date: October 27, 2006

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